

Synchrotron Radiation to study Atomic Layer Deposition

Monday, 13 June 2016

Posters (14:30 - 16:00)

[id] title	presenter	board
[48] BOREAS: Polarization-dependent Soft X-ray Absorption and Resonant Scattering Beamline	Dr GARGIANI, Pierluigi	
[49] Monitoring of Atomic Layer Deposition by Infrared Spectroscopy	KREUZER, Martin	
[47] The non-crystalline diffraction beamline at ALBA	MARTINEZ, Juan Carlos	
[42] CLÆSS: the Core Level Absorption & Emission Spectroscopies Beamline at ALBA	Dr SIMONELLI, Laura	
[41] Near Ambient Pressure Photoemission at ALBA	Dr ESCUDERO, Carlos	
[7] Visualizing the incipient growth of ZnO ultra thin films on InGaAs for tailoring contact resistivity	Mr SKOPIN, Evgenii	
[14] A Future Path for Selective Atomic Layer Deposition	Mrs KORNBLUM, Noga	
[11] ALD of Titanium Dioxide Films Used as Protective Coatings for Photoelectrochemical Cells	Mr HAJDUK, Andreas Mr COTTRE, Thorsten	
[15] In Situ GISAXS Characterization of ALD in Mesoporous Thin Films	Dr DENDOOVEN, Jolien	
[17] Phase Transitions in Compositionally Graded Ferroelectric Superlattices	Mrs RAZUMNAYA, Anna	
[19] Atomic layer deposited HfO₂-based magnetic tunnel junctions	Dr THOMAS, Andy	
[34] Untangling Diffraction Contributions from Epitaxial Thin Films	Mr SØNSTEBY, Henrik	